Supporting Information for

Regulating the electronic properties of WGe₂N₄ monolayer by adsorption of 4d transition metal atoms towards spintronic

devices

Jin-Lan Sun, Mi-Mi Dong, Yue Niu, Zong-Liang Li, Guang-Ping Zhang, Chuan-Kui

Wang*, Xiao-Xiao Fu*

Shandong Key Laboratory of Medical Physics and Image Processing & Shandong

Provincial Engineering and Technical Center of Light Manipulations, School of

Physics and Electronics, Shandong Normal University, Jinan 250358, China

*E-mail: ckwang@sdnu.edu.cn; fuxiaoxiao@sdnu.edu.cn

Table S1. The adsorption energies (E_a) , adsorption distances (D), magnetic moments (M) and band gaps (E_{gap}) of the WGe₂N₄ monolayer adsorbing 4d transition metal atoms (Y–Cd) with the most stable adsorption structures.

| ТМ | Y | Zr | Nb | Mo | Tc | Ru | Rh | Pd | Ag | Cd |
|------------------------|-------|-------|------|-------|-------|-------|-------|-------|-------|-------|
| $E_{\rm a}/{\rm eV}$ | -2.66 | -1.93 | -1.6 | -0.56 | -1.00 | -1.80 | -1.93 | -1.60 | -0.49 | -0.30 |
| $D/{ m \AA}$ | 1.10 | 1.78 | 1.31 | 2.38 | 2.16 | 1.78 | 1.79 | 1.90 | 2.53 | 3.06 |
| $M/\mu_{ m B}$ | 0.77 | 3.02 | 2.90 | 5.62 | 4.98 | 2.01 | 0.96 | 0.00 | -0.02 | 0.00 |
| $E_{\rm gap}/{\rm eV}$ | 0.00 | 0.00 | 0.00 | 0.00 | 0.09 | 0.12 | 0.18 | 0.66 | 0.00 | 0.60 |



Fig. S1 The band structures of the WGe₂N₄ monolayer with 4d transition metal adatoms (Y, Zr, Mo, Tc, Ru, Pd, Ag, and Cd).



Fig. S2 The orbital projected band structures of the (a) Nb- and Rh-adsorbed WGe_2N_4 monolayer. In order to observe the occupation of the atomic orbitals of the Nb-adsorbed system more clearly, the occupation of the orbitals of Nb, W, and N atoms are plotted separately.



Fig. S3 The zero-bias transmission spectra of Sc-adsorbed WGe_2N_4 device with the central region containing 6, 7, and 8 units with parallel magnetization configuration.